## Enhanced shot noise in resonant tunnelling via interacting localised states

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In a variety of m esoscopic systems shot noise is seen to be suppressed in comparison with its Poisson value. In this work we observe a considerable enhancement of shot noise in the case of resonant tunnelling via localised states. We present a model of correlated transport through two localised states which provides both a qualitative and quantitative description of this e ect.

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Understanding the role of electron coherence and Coulomb interaction in electron transport is one of the main directions of contemporary research in mesoscopic physics. Recently, shot noise measurements have proved to be a useful tool for these studies, since they provide information which is not available from standard conductance m easurem ents [1]. Shot noise, i.e. uctuations of the current in time due to the discrete nature of electrons, is a measure of tem poral correlations between individual electron transfers through a mesoscopic system . Uncorrelated transfers result in the Poisson shot noise with the noise power  $S_{T} = 2eI$  (e is the electron charge, and I is the average current). The e ects on noise of the Pauliexclusion principle [2] and the Coulomb repulsion [3] turn out to be sim ilar in most mesoscopic systems. Both were predicted to impose a time delay between two consecutive electron transfers, which results in negative correlations between them and, therefore, suppression of shot noise. This idea has been intensively explored in studies of the shot noise properties in ballistic and di usive systems [4,5].

Electron transport via localised states in a potential barrier between two contacts has been a subject of intensive investigations. If the size of a mesoscopic barrier is small, resonant tunnelling (RT) through a single localised state (impurity) becomes responsible for conduction across the barrier [6]. W hen the resonant level (R) coincides with either of the Ferm i levels in the contacts,  $_{\rm L\,;R}$ , a peak in the conductance appears. The am plitude of the peak is determ ined by the ratio of the leak rates  $_{L;R}$  / exp (  $2r_{L;R}$  =a) from the resonant in purity to the contacts, where  $r_{L,R}$  are the distances between the impurity and the left or right contacts, and a is the localisation radius of the state, Fig.1a. The current is given by the relation  $I_0 = e_L R = (L + R)$ . It has been predicted in [7, 8] that for RT via a localised state shot noise is suppressed by the Fano fac- $S_{I}=2eI_{0} = \frac{2}{L} + \frac{2}{R} = (L + R)^{2}$ . The Fano tor F factor then ranges from 0.5 (for equal rates) to 1 (for signi cantly di erent rates) dependent on the position of the resonant in purity inside the barrier. Suppression of shot noise in accordance with this relation has been rst

observed in a resonant tunnelling structure [9]. Sim ilar suppression of shot noise in the C oulom b blockade regime has been seen in a quantum dot [10]. In electron hopping (sequential tunnelling) through N equivalent barriers the Fano factor is also expected to be suppressed, F = 1=N, if one assumes that the P oisson noise is generated across a single barrier [11].

In this work we present a study of time-dependent uctuations of the RT current through a short (0.2 m) tunnel barrier. Surprisingly, we observe a signi cant enhancement of shot noise with respect to the Poisson value. We explain this elect by correlated resonant tunnelling involving two interacting localised states.

The experiment has been carried out on a n-G aAs M ESFET consisting of a G aAs layer of 0:15 m (donor concentration  $10^{17}$  cm<sup>3</sup>) grown on an undoped G aAs substrate. On the top of the structure an Au gate is deposited with dimensions L = 0:2 m in the direction of the current and W = 20 m across it, Fig.lb. By applying a negative gate voltage, V<sub>g</sub>, a lateral potential barrier is form ed between the ohm ic contacts (source and drain).

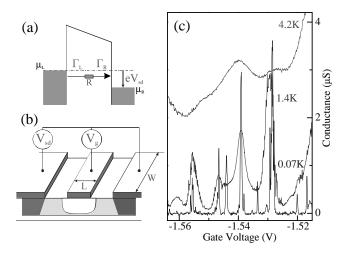


FIG.1: (a) Resonant tunnelling through a localised state in a barrier. (b) Cross-section of the transistor structure with two ohm ic contacts and the gate between them. (c) Typical RT peaks in the ohm ic conductance at di erent temperatures.

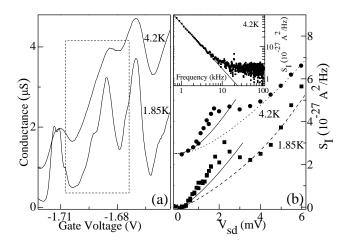


FIG.2: (a) C onductance peaks in the region of  $V_g$  where the current noise has been m easured. (b) Shot noise power as a function of  $V_{\rm sd}$ : at  $V_g$  = 1:6945 V for T = 1:85 K and  $V_g$  = 1:696 for T = 4.2K. Lines show the dependences  $S_{\rm I}$  ( $V_{\rm sd}$ ) expected for resonant tunnelling through a single in purity from Eq.(1), with F = 1 (solid), F = 0:63 (dashed), and F = 0:52 (dotted). Inset: Excess noise spectrum at  $V_g$  = 1:696 V and  $V_{\rm sd}$  = 1:5 m V.

Its height is varied by changing  $V_g$ . W hen a source-drain voltage  $V_{sd}$  is applied, uctuations of the current between the ohm ic contacts are measured by two low-noise am - pli ers. The cross-correlation spectrum in the frequency range 50 100 kHz is detected by a spectrum analyzer [12]. This technique rem oves noise generated by the am - pli ers and leads.

Fig.1c shows an example of conductance peaks as a function of V<sub>g</sub> in the studied sample at V<sub>sd</sub> = 0 and different temperatures down to T = 0.07 K. One can see that with lowering temperature the background conduction (due to electron hopping) decreases and the amplitude of the conductance peaks increases. This increase is a typical feature of resonant tunnelling through an impurity [6].

The box in Fig 2a indicates the range of  $V_g$  where shot noise has been studied at 1.85 K < T < 4.2 K. In Fig 2b (inset) an example of the excess noise spectrum is shown at a gate voltage near the RT peak in Fig 2a. (In this spectrum therm al noise has been subtracted and the effect of the stray capacitance has been taken into account according to [12].) Shot noise is determined from the at region of the spectrum above 40 kHz. In this region one can neglect the contribution of 1=f noise ( = 1:6) which is shown in Fig 2b (inset) by a solid line.

Fig.2b shows the dependence of the shot noise power on  $V_{sd}$  at two temperatures. At small biases ( $V_{sd} < 3$ mV) a pronounced peak in noise is observed with an unexpectedly large Fano factor F > 1. This is seen by plotting the dependences  $S_I$  ( $V_{sd}$ ) with di erent F using the phenom enological expression for excess noise in the case of RT through a single impurity (cf. Eq.(62) in [1] and Eq.(11) in [8]):

$$S_{I} = F 2eI_{sd} \operatorname{coth} \frac{eV_{sd}}{2k_{B}T} \qquad F 4k_{B}TG_{S}:$$
 (1)

(The expression describes the evolution of excess noise into shot noise  $S_I = F 2eI_{sd}$  at  $eV_{sd} > k_B T$ ;  $G_S$  is the ohm ic conductance of the sam ple) At large biases ( $V_{sd} > 3 \text{ mV}$ ), however, shot noise decreases to a conventional sub-Poisson value, F = 0.6.

We have established that the increase of shot noise exists only in a speci c range of  $V_g$ . It is worth noting that there is no negative di erential conductance in the region of  $V_{\rm sd}$ - $V_g$  where the peak in the noise appears, and, therefore, we cannot link this enhancement to some sort of instability [13]. Instead, we will show that in this region of  $V_{\rm sd}$ - $V_g$  the resonant current is carried by two interacting impurities and this leads to the increase of shot noise.

We will rst show that interaction between two states can considerably increase shot noise. Let us start with a simple illustrativem odel and consider two spatially close impurity levels, R and M , separated in the energy scale by 4 . If im purity M is charged, the energy level of R is shifted upwards by the Coulomb energy U é= r, where r is the separation between the impurities and is the dielectric constant, Fig.3 (diagram 1). Thus, dependent on the occupancy of M, impurity R can be in two states: R1 or R2. Further we assume that  $V_{sd}$  is sm all enough so that state R 2 is above the Ferm i level in the left contact, Fig.3 (diagram 2). Then electrons are transferred via R with the rates  $L_{L,R}$  if M is empty, and cannot be transferred if M is charged. It is assumed that impurity M changes its states independently of the state of impurity R: from empty to charged state with the rate X  $_{\rm c}$  and from charged to empty state with the rate X<sub>e</sub>. If M changes its occupancy at a slow rate, i.e.  $_{\rm L\ ;R}$  , its contribution to the current is negligible X<sub>e;c</sub> and we will call M a modulator since it modulates the current through impurity R. This current jumps random ly between two values: zero, when M is occupied, and  $I_0$  when M is empty, Fig.3 (inset). If the bias is increased, the upper state R2 is shifted down into the conducting energy strip and the modulation of the current via impurity R vanishes, Fig.3 (diagram 3).

In the m odulation regime, the average current through impurity R and the corresponding zero-frequency Fano factor can be written, respectively, as

$$I = \frac{e_{L} R}{L + R} \frac{X_{e}}{X_{e} + X_{c}}$$
(2)

and

$$F = \frac{\frac{2}{L} + \frac{2}{R}}{\left(\frac{1}{L} + \frac{2}{R}\right)^{2}} + 2 \frac{\frac{1}{L} - \frac{R}{R}}{\frac{1}{L} + \frac{1}{R}} \frac{X_{c}}{\left(X_{e} + X_{c}\right)^{2}} : \quad (3)$$

The rst term in Eq.(3) describes the suppression of the Fano factor below unity [8], whereas the second term

gives a positive contribution. To illustrate the origin of the second term, one can think of the modulated current as random telegraph noise (RTN), i.e. spontaneous  $\lim ps$  between zero and  $I_0$ . The second term can then be obtained from the spectrum of RTN [14] with characteristictimes of the upper and lower states  $-1=X_e$  and  $1=X_c$ , respectively. If X e;c L;R, a substantial enhancem ent of shot noise, F 1, is expected from Eq.(3). Another way to illustrate the origin of this e ect is to assume that M is close to the left contact. As a result, in purity M spends m ore tim e in its charged state, i.e. X e X<sub>c</sub> and the current through R is transferred in bunches, with the average duration of a bunch  $_{e} = 1=X_{c}$ . The noise due to the 'chopping' of the current can then be estim ated as  $S_I = 2Q I$ , where Q is the average charge transferred in one bunch. This charge is equal to  $I_0 e_{\ell}$  and this again gives the second term in Eq.(3).

Thism odelofa slow modulatorwhich changes its state independently of impurity R may look too simplistic. However, its generalisation (for any relation between X and ) is straightforw and and provides a consistent quantitative description of the observed e ect. Our theoretical model is based on the master equation form alism [8, 16]. It is applicable when  $L_{L,R} < k_B T$  -the condition satisfied in our experiment. Then the system of two interacting impurities R and M can be in four possible states. The transition rates between these states are determined by tunnelling between the contacts and impurities and depend on tem perature and the level positions with respect to the Ferm i levels  $_{L,R}$  . The resulting transport problem is reduced to num erical diagonalisation of a 4 4 matrix. As a result, the current and the Fano factor are obtained as a function of the energy positions of the two impurities, which are linearly dependent on  $\ensuremath{\text{V}_{\text{sd}}}$  and  $V_{q}$ . It is important that in our calculations the elect of tem perature, which suppresses the enhanced Fano factor in Eq.(3), is taken into account. (In a sim ilar master equation approach an increase of shot noise for two interacting quantum dots was also obtained in [17], however at T = 0.)

By measuring the di erential conductance as a function of  $V_{q}$  and  $V_{sd}$  we have been able to show directly that the increase of shot noise occurs in the region of V<sub>q</sub>-V<sub>sd</sub> where two interacting in purities carry the current in a correlated way. Fig.3 presents the grey scale of the differential conductance plotted versus  $V_q$  and  $V_{sd}$ . When a source-drain bias is applied, a single resonant in purity would give rise to two peaks in dI=dV ( $V_{\alpha}$ ), which occur when the resonant level aligns with the Fermi levels  $L_{R}$ . On the grey scale these peaks lie on two lines crossing at  $V_{sd} = 0.$  Consider, for example, point M in Fig.3. The central area between the lines corresponds to the im purity level between  $_{\rm L}$  and  $_{\rm R}$ , that is when the impurity is in its conducting state. Outside this region the impurity does not conduct, as it is either empty (on the left of the central region) or led (on the right of it).

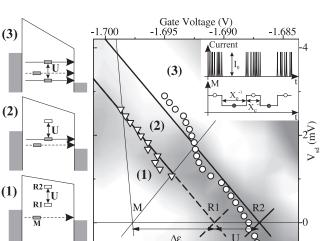


FIG.3: Left panel: Energy diagram s of the two in purities for di erent positive  $V_{\rm sd}:V_{\rm sd}^{(1)} < V_{\rm sd}^{(2)} < V_{\rm sd}^{(3)}$ . Inset: Schem atic representation of the modulation of the current through in – purity R by changing the occupancy of modulator M . M ain part: G rey-scale plot of the di erential conductance as a function of  $V_{\rm g}$  and  $V_{\rm sd}$  at T = 1:85 K (darker regions correspond to higher di erential conductance, background hopping contribution is subtracted). Lines show the positions of the conductance from the tting of the noise data in Fig.4.

Experimentally, at small  $V_{sd}$  we see such a cross-like feature near point R 2, with the left line being more pronounced. The exact positions of the maxim a of the conductance peaks of this line are indicated by circles. It is seen that with increasing  $V_{sd}$ , a new parallel line R 1 appears at  $V_g$  1:694 V and  $Y_d$  1 m V, shifted to the left by 4  $V_g$  4 m V. The maxim a of the conductance peaks of this line are shown by triangles.

In Fig.3 the m odulator cross is plotted according to the analysis below – experimentally we cannot observe these lines because the m odulator conductance peaks are too small, due to low leak rates  $X_e$  and  $X_c$ . The R 1-line occurs in the inner region of the m odulator cross, i.e. where the m odulator occupancy changes in time. Therefore, lines R 1 and R 2 reject the C oulomb shift of level R: the former corresponds to the empty m odulator and the latter – to the occupied one. The m odulation of the current should then occur in region (2), Fig.3: the central part of cross M between lines R 1 and R 2, corresponding to diagram (2). As discussed before, in region (3) there is no m odulation as both states R 1 and R 2 can conduct, and in region (1) there is no current as the low state R 1 is still above  $_L$ .

In Fig.4 current noise and the Fano factor are presented as functions of  $V_{sd}$  for di erent  $V_g$ . It shows that indeed the increase of noise occurs only in region (2) in Fig.3. Namely, the increase of noise appears only between  $V_g =$ 

1:699 V and  $V_g$  = 1:693 V, that is, in the central region of cross M . In addition, when  $V_{\rm sd}$  is swept at

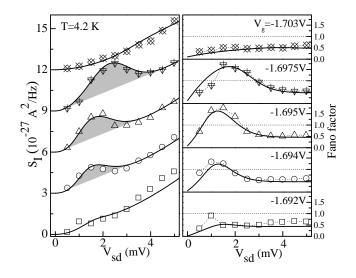


FIG. 4: Shot noise and the corresponding Fano factor as a functions of source-drain bias at di erent gate voltages. (The shot noise data for di erent  $V_g$  are o set for clarity.) Solid lines show the results of the num erical calculations.

xed  $V_g$ , one can see that the hump in the Fano factor appears only between lines R1 and R2.

In order to quantizatively compare the model with the experiment we have to take into account that in our experiment resonant tunnelling via state R exists in parallel with the background hopping. Then the total Fano factor has to be expressed as F = (F<sub>RT</sub> I<sub>RT</sub> + F<sub>B</sub> I<sub>B</sub>) = (I<sub>RT</sub> + I<sub>B</sub>), where F<sub>RT</sub>, F<sub>B</sub> and I<sub>RT</sub>, I<sub>B</sub> are the Fano factors and currents for RT and hopping, respectively. In order to get inform ation about the background hopping we have measured noise at V<sub>g</sub> >

1:681 V, i.e. away from the RT peak under study in Fig.3. It has been estimated as  $F_B$  0:4. This value of the Fano factor is expected for shot noise in hopping through N 2 3 potential barriers (1-2 in purities in series) [12, 15]). The bias dependence of the background current at this  $V_g$  is also consistent with hopping current via two in purities: dI=dV /  $V_{sd}^{4=3}$  [16].

A ssum ing that the background current is approximately the same for all studied gate voltages, we have added up the contributions to the Fano factor from RT via two interacting in purities, R and M, and the background hopping. The numerical results have been tted to the experimental dI=dV ( $V_{sd}$ ; $V_g$ ) and  $S_I$  ( $V_{sd}$ ; $V_g$ ), Fig.4. The tting parameters are the back rates of R and M (~  $_L$  ' 394 eV, ~  $_R$  ' 9:8 eV, and ~X  $_e$  ' 0:08 eV, ~X  $_c$  ' 0:16 eV ), the energy dimension for the background hopping ( $F_B = 0.45$ ). The coefficients in the linear relation between the energy levels M, R and  $V_{sd}$ ,  $V_g$  have also been found to m atch both the experimental data in Fig.4 and the position of lines R1 and R2 in Fig.3. One can see that the model gives good agree-

m ent with the experiment. The Coulom b shift (U 0:55 m eV) found from Fig.3 agrees with the estimation for the Coulom b interaction between two impurities not screened by the metallic gate: U  $e^2 = d$  1 m eV, where d 1000 A is the distance between the gate and the conducting channel.

It is interesting to note that the hopping background e ectively hampers the manifestation of the enhanced Fano factor  $F_{R\,T}$ , i.e. without the background the Fano factor enhancem entwould be much stronger. The largest experimental value of F in Fig.4 (at  $V_g = 1.6975 \, V$ ) is approximately 1.5, while a numerical value for RT at this  $V_g$  is  $F_{R\,T}$  8.

In conclusion, we have observed enhanced shot noise in resonant tunnelling via localised states in a short-barrier structure. We have demonstrated that this e ect originates from C oulom b interaction between two localised states which in poses correlations between electron transfers. A simple model is shown to provide a quantitative description of the observed enhancem ent.

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